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PCL

0321.68095

PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: Yeshaiahu Fainman)

Serial No.: 10/521,425)

Filed: January 14, 2005)

For: HOLOGRAPHICALLY DEFINED)
SURFACE MASK ETCHING METHOD)
AND ETCHED OPTICAL STRUCTURES)

Group Art Unit:)

I hereby certify that this paper is being deposited with
the United States Postal Service as first class mail in an
envelope addressed to: Assistant Commissioner for
Patents, Washington, D.C. 20231, on this date.

3/9/05
Date

Registration No. 35132

PRELIMINARY AMENDMENT

MS Amendment
Commissioner for Patents
P.O. Box 1450
Washington, D.C. 20231

Dear Sir:

Prior to examination of this application, please amend the application as
follows: